

May 29, 2019

To Whom It May Concern:

Company name: Fujimi Incorporated  
Representative: Keishi Seki, President  
Listings: Tokyo and Nagoya Stock Exchanges  
(Stock code: 5384)  
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Notice concerning Investment in FLOSFIA Inc.

Kiyosu, Aichi, May 28, 2019 – Fujimi Incorporated (TSE: 5384), a pioneer in the field of manufacturing synthetic precision abrasives as well as a leading supplier of silicon wafer lapping abrasives and polishing slurries, has acquired new shares issued by FLOSFIA Inc. in its Series D Round 2.

Fujimi's venture capital fund, "Phoenix investment limited partners" established in November 2015, has also acquired this FLOSFIA's new shares, which is the second investment following its first one in March 2017.

FLOSFIA Inc., a tech startup spun from Kyoto University, is aiming to commercialize Corundum Structured Gallium Oxide ( $\alpha$ -Ga<sub>2</sub>O<sub>3</sub>) in order to revolutionize power electronics and has already begun shipping its samples.

FLOSFIA Inc. will use this capital to build its own mass production lines of a Schottky Barrier Diode (SBD) in 2019, contributing to energy saving and the creation of new industries.

As a strategic partner, by applying its precision polishing and cleaning technology, Fujimi will collaborate with FLOSFIA to develop a process for their  $\alpha$ -Ga<sub>2</sub>O<sub>3</sub> power semiconductor.

ABOUT FLOSFIA

Company name: FLOSFIA Inc.

Address: Kyodai Katsura Venture Plaza North Bldg., 1-36, Goryo ohara, Nishikyo-ku, Kyoto 615-8245, Japan

President CEO: Toshimi Hitora

Capital: 2,910 million yen (including capital reserve)

HP : <http://flosfia.com>